

Nano- and micro-structural control of WO_3 photoelectrode films through aqueous synthesis of $\text{WO}_3 \cdot \text{H}_2\text{O}$ and $(\text{NH}_4)_{0.33}\text{WO}_3$ precursors

Hiroaki Uchiyama* and Yuki Nagayasu

E-mail address: h_uchi@kansai-u.ac.jp (H. Uchiyama).

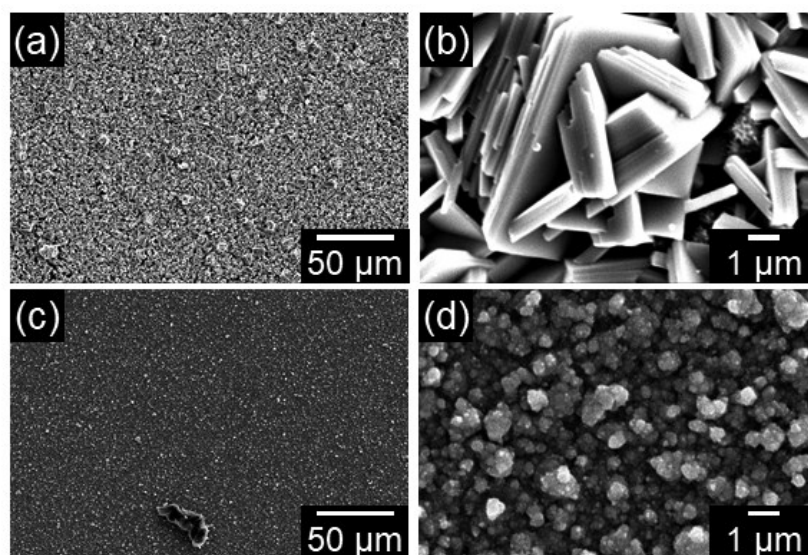


Fig. S1 SEM images of the WO_3 precursor layers prepared on silica glass substrates at $x = 0.17$ mM (aging at 60 °C for 3 days) (a–b) and 8.5 mM (aging at 50 °C for 1 day) (c–d).